

# Landau-level spectroscopy of helical Dirac fermions in a topological insulator $\text{Bi}_2\text{Se}_3$

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Topological insulators are emerging materials which have energy gap in the bulk but possess robust gapless edge (2-dimensional case) or surface (3-dimensional case) states [1,2]. In 3-dimensional case, the surface state is characterized by Dirac fermions which would give rise to unique quantum phenomena in a magnetic field [3]. Although the Dirac surface state has been confirmed by angle-resolved photoemission spectroscopy (ARPES) experiments, magnetic-field effects on a topological insulator are poorly understood because ARPES is not magnetic-field compatible and contributions from bulk bands dominate magneto-transport properties.

Here we use scanning tunneling spectroscopy to study the Dirac surface state of a topological insulator  $\text{Bi}_2\text{Se}_3$  under magnetic fields [4].  $\text{Bi}_2\text{Se}_3$  crystals are naturally doped with electrons and the Dirac point is located  $\sim 0.3$  eV below the Fermi level. Under magnetic field perpendicular to the cleaved surface, a series of Landau levels (LLs) has been observed in the tunneling spectrum. Remarkably, there is a field-independent LL at the Dirac point, which is a hallmark of Dirac fermions. We developed a scaling analysis scheme of LLs based on the Bohr-Sommerfeld quantization condition which allowed us to determine the energy-momentum dispersion of the surface state. Near the Fermi energy, complicated fine structures mixed with LLs appear in the spectra, which may be responsible for the anomalous magneto-fingerprint effect [5]. We anticipate that these observations provide spectroscopic basis for understanding the nature of topological insulators under magnetic fields.

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